

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Group Art Unit: 2851 Examiner: Hung Nguyen Confirmation No.: 6971

Re PATENT APPLICATION Of:

Applicants:

Ryoichi AOYAMA et al.

Serial No.:

10/748,240

Filed:

December 31, 2003

For:

SELF-CLEANING METHOD FOR

SEMICONDUCTOR EXPOSURE

APPARATUS

Allowed:

August 5, 2005

Docket No.: OKI 395

September 30, 2005

AMENDMENT AFTER ALLOWANCE

MAIL STOP ISSUE FEE

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

Pursuant to 37 CFR § 1.312, please amend the above-identified application as

follows: